

# Developing SiC for Optical System Applications

SPIE 2004  
2 Aug 2004

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# Motivation

- **Silicon carbide is a new material with potential for making large lightweight mirrors and systems quickly and cost-effectively**
- **Is this material ready for insertion into future systems, especially in space systems?**
- **How do we characterize and develop this material for future needs?**

# Outline

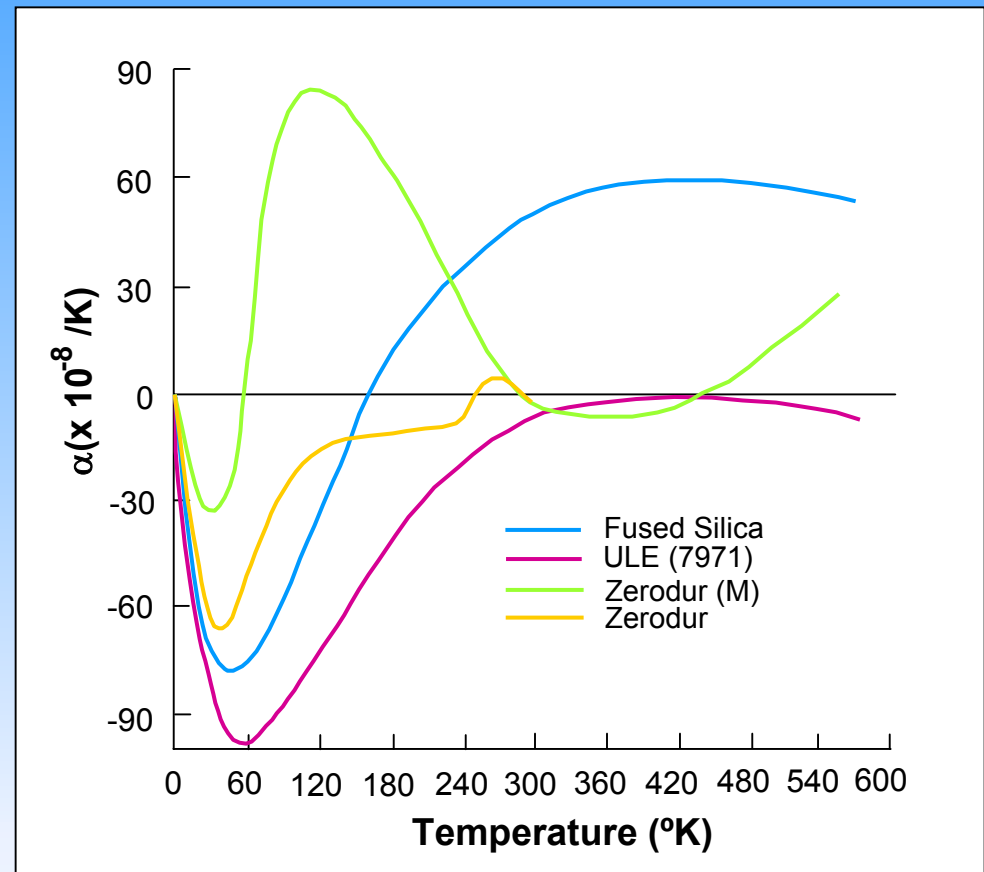
- **Space application requirements**
- **Existing material overview**
- **Why SiC?**
- **SiC descriptions**
- **Evolution of SiC from substrate to system material**
- **Future work**
- **Recommendations**
- **Summary**

# Space Application Needs and Goals

- **Build large aperture mirrors**
  - Apertures >3 m in diameter are of interest
  - Low areal density, currently  $\approx 15\text{kg/m}^2$ , goal 1 – 5 kg/m<sup>2</sup>
- **Choose materials that maintain optical performance from launch through on-orbit operations**
  - Radiation environment
    - Maintain optical performance even with radiation exposure: AO, UV, electrons, micro debris etc
    - Develop model to predict behavior
  - Material and structural stability
    - Maintain optical performance during launch and temperature variations on orbit
- **Reduce risk by using material with extensive space heritage**
  - Rely on engineering experience
  - Design systems using established design trades
- **Reduce cost of developing new space materials**
  - Develop cost-effective substrate production, optical finishing, and coatings
  - Perform space environment testing

# Low CTE Mirror Materials

- **Glass**
  - Fused silica
  - ULE
  - Zerodur
- **Metals**
  - Beryllium
- **Alternatives**
  - Composites
  - SiC



Source: Stephen Jacobs, SPIE Vol 1335

- **Operating parameters dictate material selection**
  - Room temperature, Zerodur and ULE good choices
  - Cryogenic temperatures, less than 123K, fused silica may be better choice

# Glass vs Be vs SiC

- **Glass**

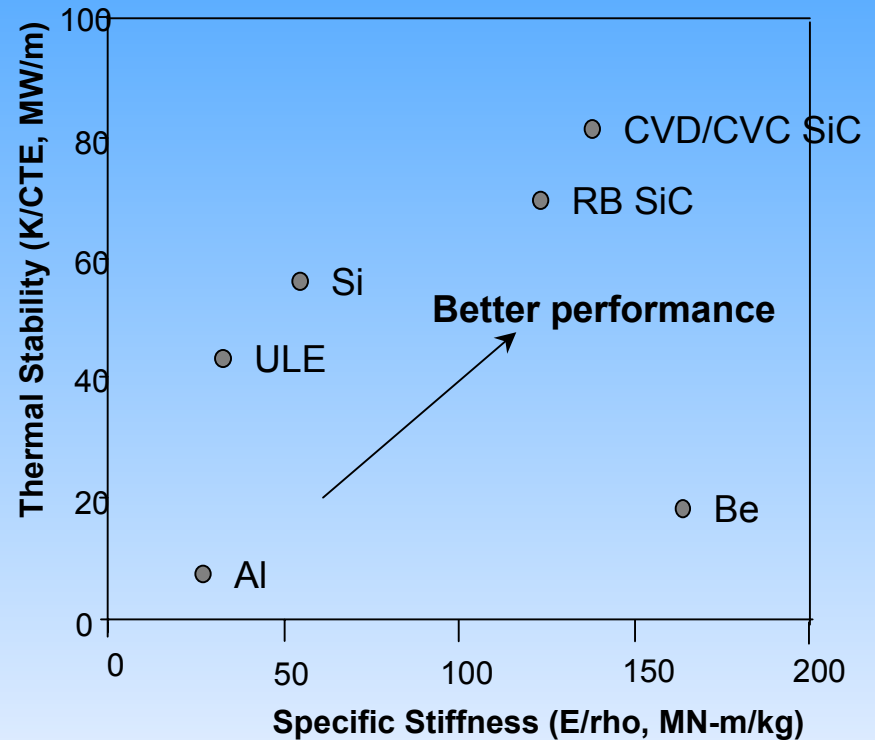
- Extensive space heritage
- Easily figured and polished
- Long lead times for large-diameter applications

- **Be**

- Space heritage, used for structures and mirrors
- Established material, proven long-term stability
- Uncertain supply and challenges of toxicity

- **SiC**

- High thermal conductivity, low thermal expansion, high specific stiffness, can be lightweighted
- Multiple suppliers, inexpensive substrates
- Good potential for space applications
- Limited space heritage and difficult to polish to an optical surface



Source: Trex Enterprises

- **All materials are susceptible to radiation effects to varying extents**

- Materials have a change in density
- Compaction or expansion can occur
  - Changes can affect radius of curvature

# Choosing SiC: Systems engineering approach

- **Using a single property to choose a material must be avoided, must examine all parameters and application**
- **Evaluate replacement of existing materials with SiC on case-by-case basis**
  - **May not be possible to replace only one component of a system with SiC**
  - **Decision may require reengineering of entire system**
  - **Introduction of SiC may be more successful in new projects and technology developments**
- **Resistance may exist when replacement of well-known components with higher risk materials is suggested**
  - **Reengineering and unknown performance**

# SiC Mirrors vs. Structures

- **Complete SiC system is passively athermal instrument**
  - Challenges in mounting and assembly of system
    - Inserts, bonding, SiC screws
- **Somewhat different requirements for mirror vs structures**
  - Solution is application driven
- **Structures**
  - High fracture toughness
  - Specific stiffness may not need to be as high
    - Require more weight (Fiber reinforced)
  - Uniformity not as critical, if high fracture toughness is key
- **Mirrors**
  - High specific stiffness, enables lightweighting
  - Polishable, create optical surface
  - High uniformity, maintain optical performance

*Mirrors and structures may require two  
different forms of SiC*



# SiC Production Methods

- **Chemical Vapor Deposition (CVD):** fully dense single-phase SiC, zero porosity
- **Sintering:** trace amounts of a second phase from sintering, porosity 2 – 5%
- **Reaction bonding:** two-phase mixture of SiC and silicon metal (6 to 40%), porosity 0 – 15%
- **Graphite or carbon conversion:** single-phase (monolithic) structure with porosity up to 20%; if carbon fibers, unconverted Gr or C, or Si present, at least two-phase material
- **Hot Isostatic Pressing (HIP):** fully dense SiC with minor amounts of a second phase from additive used as a hot pressing aid, porosity <1%
- **Foam:** fully distributed load paths under mirror surface, easier metrology mount, higher stiffness and first mode frequency, porosity 85 – 95%

# Porosity and Contamination

- **Open Pores**
  - Increased probability of contamination during fabrication
  - Migration and deposition of outgassed contaminants in vacuum
    - Onto optical surface(s) during coating process
    - Onto critical telescope components (e.g. focal plane arrays) on orbit
- **Closed pores**
  - Trapped gasses
    - Surface deformation due to pressure difference between fabrication and vacuum/on-orbit environments

# SiC Phase Descriptions and Optical Challenges

- **SiC can come in different phases**
  - Single phase: pure SiC
  - Two-phase: SiC plus Si
  - Three phase: carbon fibers, SiC, Si example: CeSiC
- **SiC with different phases make optical finishing a challenge**
  - Single phase is a hard surface, difficult to polish
  - Two phase is more difficult to polish as SiC and Si polish at different rates requiring CVD coating for optic quality
  - Three phase can have fiber print through

# Processing Challenges

- **CVD: time to create monolithic part, limit on size**
- **Sintering: press-limited size, green body integrity during machining, controlled shrinkage during sintering, brazing required for large diameter parts**
- **Reaction bonding: polishing, mold quality**
- **HIP: expensive, limit on shapes**
- **Graphite or Carbon conversion: complete conversion, green body integrity during machining, multiple phases**
- **Foam: polishing optical surfaces, scaling to large diameters**
- ❖ ***Different methods produce slightly differing SiC properties, which can vary up to 20% in value***
- ❖ ***Greatest difference among manufacturing methods is costs and processes to make an optical part***

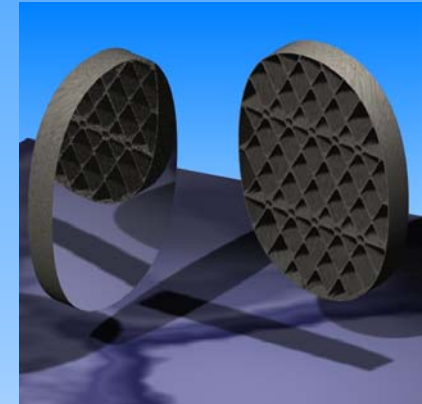
# US SiC Manufacturers



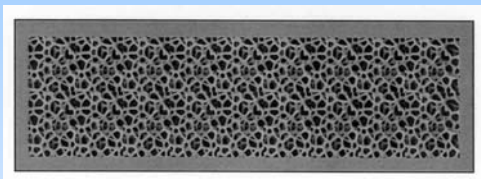
Source: CoorsTek



Source: M Cubed



Source: POCO



Source: Schafer



Source: SSG



Source: Trex



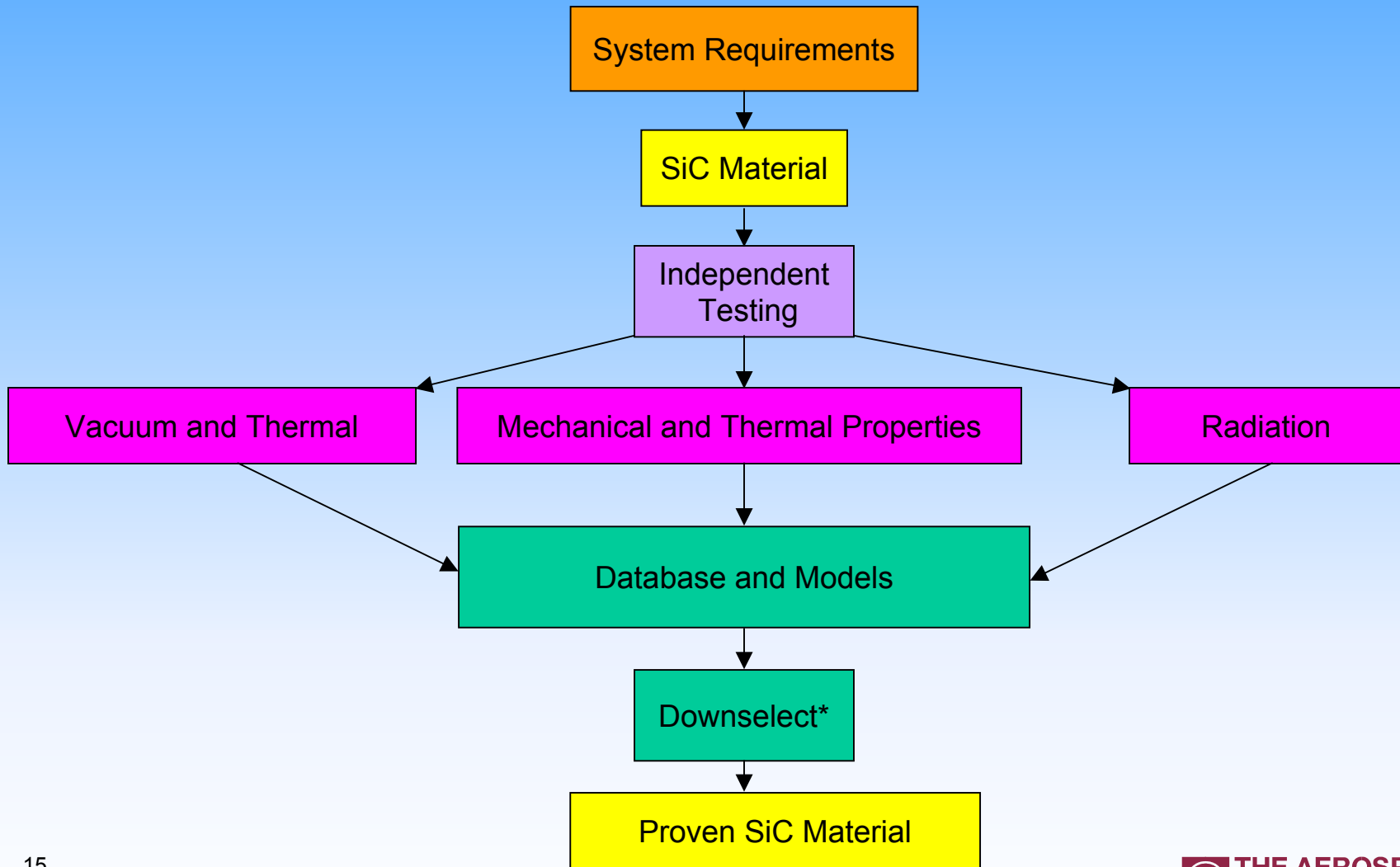
Source: Xinetics  
Iwona.A.Palusinski@aero.org

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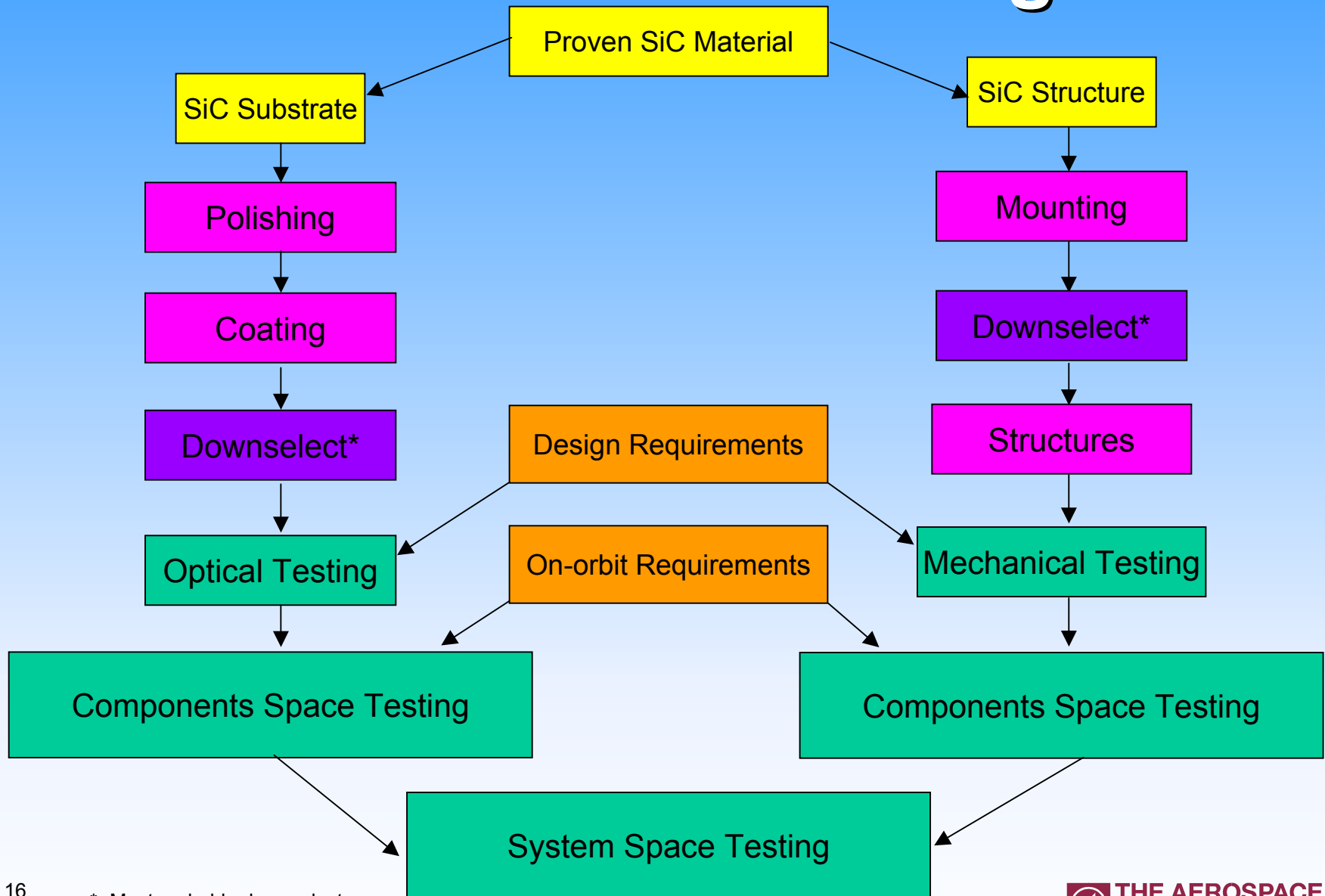
# Evolution of SiC from Substrate to System Material

- **Collaborate with multiple agencies to qualify materials**
  - NASA, AFRL, MDA
  - Share resources, develop multi-application requirements
- **Verify consistency of SiC production**
- **Space qualify SiC not only as substrate material but as a system material**
  - **Develop mirror substrate and structural samples**
    - Test variety of SiC such as reaction bonded, sintered, foams, and three phase materials
    - Investigate both coated and uncoated SiC substrates
  - Perform radiation, thermal, and vacuum testing
- **Downselect to optimal forms of SiC via testing**
- **Develop polishing and coating technology**
  - Techniques will be SiC-type dependent

# SiC Material Qualification Flow Diagram



# SiC Evolution Flow Diagram





# Testing and Future Work

- **Characterize SiC as a substrate and structural material**
  - Perform material and optical testing
    - 2-stage test matrix
      - Screening – most critical properties: CTE, stiffness
      - Characterization – full materials testing
    - Reduce cost of materials development
      - Identify manufacturers with greatest potential early
      - Invest consolidated funds into companies that meet space environment requirements
        - Pursue SiC system development
- **Perform space environment testing**
  - Earth simulation of atomic oxygen, radiation effects
  - On-orbit testing, combined effects
- **Develop and validate models of radiation effects on SiC**
  - Compare on-ground orbit simulation with on-orbit exposure

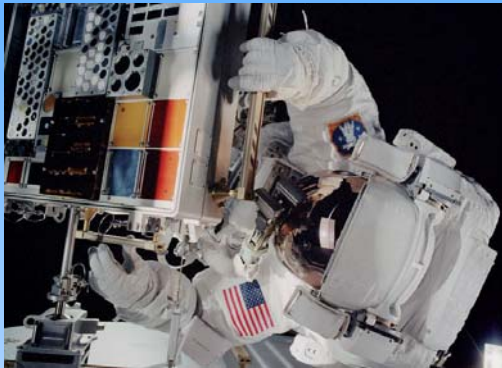
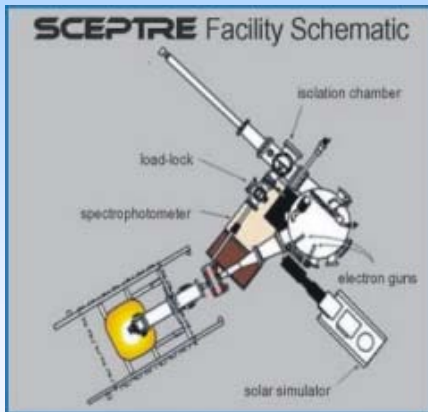


Photo courtesy of NASA/MSFC



Drawing courtesy of AFRL/ML

# Recommendations

- **Continue funding development of various forms of SiC**
- **Encourage collaboration with various government agencies and non-profit organizations for independent evaluation of SiC**
- **Develop groundwork for development of established polishing and coating techniques, will vary with SiC type**
- **Characterize various forms of SiC from material, optical, and structural perspective**
- **Fund demonstration program that uses a SiC system**
  - **Validate material, optical, and structural characteristics of SiC**
  - **Produce multiples of a system to validate production processes**
  - **Increase diameters to meter class or greater**

# Summary

- **SiC has attractive qualities for space applications**
- **Several US SiC manufacturers producing various forms of SiC**
- **US programs are interested in pursuing SiC as an alternate material**
- **SiC must evolve from substrate material to systems engineering material for full implementation**
- **Develop radiation effects modeling**
  - **Required to predict behavior of future systems**